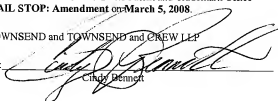


I hereby certify that this correspondence is being filed via  
EFS-Web with the United States Patent and Trademark Office  
**MAIL STOP: Amendment on March 5, 2008.**

TOWNSEND and TOWNSEND and CREW LLP

By:

  
Cindy Demott

PATENT

Attorney Docket No.: 16301M-021300US

Client Ref. No.: AM2119/PCT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of:

Karl Littau et al.

Application No.: 08/893,917

Filed: July 11, 1997

For: REMOTE PLASMA CLEANING SOURCE  
HAVING REDUCED REACTIVITY WITH  
A SUBSTRATE PROCESSING CHAMBER

Customer No.: 57385

Confirmation No. 8435

Examiner: Rudy Zervigon

Technology Center/Art Unit: 1763

**AMENDMENT**

**MAIL STOP: AMENDMENT**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

This paper is filed in response to the Office Action mailed September 5, 2007 (the "Office Action"). A three-month extension of time is also filed herewith, therefore rendering this response timely. In response to the Office Action, please enter the following amendments and remarks:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 6 of this paper.